

Hall Handbook

April 2016

Abstract

Theory and practice of the usage of the apparatus to measure Hall effect, Energy gap and Resistance of a germanium sample over a wide range of temperatures.

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Introduction

Edwin Herbert Hall discovered the “Hall effect” in 1879 while working on his doctoral thesis in Physics investigating the influence of magnets on the resistance of a coil excited by a current. Hall discovered that a magnetic field would skew equipotential lines in a current-carrying conductor. This effect is observed as a voltage (Hall voltage) perpendicular to the direction of the current in the conductor.

The magnitude of this discovery is even more impressive considering how little was known about electricity in his time. The electron, for instance, was not

identified until more than 10 years later.

The “Hall effect” remained a laboratory curiosity until the latter half of the XX century because the materials available, such as metals, would only produce small Hall voltages. With the advent of semiconductor technology and the development of various III-V compounds, it became possible to produce Hall voltages many orders of magnitude greater, allowing the production of Hall sensors, mostly made of indium antimonide (InSb), indium arsenide (InAs) and gallium arsenide (GaAs).

A macroscopic approach to Ohm’s laws

The usual *macroscopic* approach to electrical conduction is based on the following experimental observations on metallic conductors:

- 1) The application of a steady voltage difference V to a metallic wire produces a steady electric current I proportional to V . This holds true at least for small values of I when the temperature of the wire does not increase appreciably.

This allows the definition of the *electric resistance* as follows, according to the first Ohm’s law:

$$R = \frac{V}{I} \quad (1)$$

- 2) For high currents the wire temperature increases and the power $W = VI$ supplied by the generator to the moving charges, instead of accelerating more and more the circulating charge, is converted into heat (Joule effect).

It could appear that the moving charges are subjected to some kind of force, like a body falling in a viscous medium, so that they reach a steady motion and give up part of their kinetic energy to the “body” of the wire (i.e. to the crystal lattice).

- 3) The resistance R increases with increasing temperature.
- 4) Using wires of different length l and sections S the second Ohm’s law determines the resistance:

$$R = \frac{\rho l}{S} \quad (2)$$

where the constant ρ (the *electrical resistivity*) has a characteristic value for any material and increases with temperature.

The inverse quantity, the *electrical conductivity* σ , can be expressed using the two Ohm’s laws as:

$$\sigma = \frac{1}{\rho} = \frac{J}{E} \quad (3)$$

where J is the current density and E the electric field intensity. This is the starting relation needed to pass to a *microscopic* picture, that will allow a better understanding of the phenomena.

A semiclassical microscopic model

The simplest microscopic model one can use is the “free electron gas” model of metals, in which the valence electrons are supposed to be practically free from their original atoms, and thus to move in the crystal lattice formed by the metal ions. In the absence of an applied electric field, the electron velocities are randomly distributed, with zero mean value and a *root mean square* value v_m that may be evaluated from the equation:

$$\frac{1}{2}mv_m^2 = \frac{3}{2}kT \quad (4)$$

where k is the Boltzmann constant, m the electron mass and T the absolute temperature: at room temperature v_m turns out to be of the order of $10^5 m/s$.

Only when an electric field is externally applied the electron motion acquires an ordered component with a *mean value* v_d (the *drift velocity*) which turns out to be very small with respect to v_m as we will show later.

The drift velocity, i.e. this ordered component of the motion due to the electric field and to the scattering of the electrons with the lattice, is simply proportional to the electric field intensity. The constant ratio between v_d and E (both in modulus) is called the *drift mobility* μ .

During a time t of free motion between two collisions, the electrons increase their speed of the quantity:

$$at = \frac{qE}{m}t \quad (5)$$

where q is electron charge. The kinetic energy of the electrons also increases, but it can be assumed that with each collision they loose additional energy. The transfer of such energy to the lattice ions explains the Joule effect.

In figure 1 it can be noticed¹ that , after the application of the electric field, the average speed of the electrons is not zero but instead:

$$v_d = a\tau = q\tau \frac{E}{m} \quad (6)$$

¹See for instance *The Feynman lectures on Physics* vol.I 43-1,3 Addison-Wesley 1963.

where τ is the mean free time between collisions², so that the drift mobility μ has the microscopic expression :

$$\mu = \frac{v_d}{E} = \frac{q\tau}{m} \quad (7)$$

Using these concepts of drift speed and mobility the current density J can be written as:

$$J = qn v_d \quad (8)$$

where n is the free electron concentration and relation (3) and (7) allow us to give a *microscopic definition* of the electrical conductivity:

$$\sigma = qn\mu \quad (9)$$

Relation (9) tells us that all the physics of electrical conduction is described by the two parameters n and μ .

In the electron gas model n should be, for a monovalent metal:

$$n = \frac{N_A m}{\delta} \quad (10)$$

where N_A is Avogadro's number, m is the atomic mass and δ the density. As an example $n = 8.5 * 10^{28} m^{-3}$ for copper. Of course n should not depend on the temperature.

A rough order of magnitude for the electron mobility may be derived using (7). A reasonable value for τ is: $\tau \approx \lambda / v_m$, where λ is the electron mean free path, of the order of the interatomic distance in the metal (i.e. a few Å) so that, at room temperature, τ is of the order of $10^{-15} s$.

Using the values of the elementary charge $e = 1.6 * 10^{-19} C$ and of the electron mass $9.1 * 10^{-31} kg$, the electron mobility $\mu = \frac{e\tau}{m}$ should be of the order of some $\frac{cm^2}{Vs}$.

Even for very large electric fields (up to $10^2 \frac{V}{cm}$) the drift velocity $v_d = \mu E$ is thus much smaller than v_m .

Drift mobility should decrease with increasing temperature³ because of the increased thermal vibrations of the lattice ions. This effect can be studied by measuring the dependence of the electrical conductivity on temperature, but only if the free carrier concentration is the same at all temperatures.

²This time τ does not depend on the electric field because the average speed increment due to the applied electric field V_d is very small with respect to the r.m.s. speed V_m due to thermal motion .

³Drift mobility in semiconductors decreases with the absolute temperature T as T^{-a} , where $1.5 < a < 3.0$ depending on the prevailing type of interactions of the free carriers (with phonons, lattice defects, or impurities).

In order to check experimentally the microscopic model we must measure not only the electrical resistance (which gives the product of n and μ) but also the free charge density n : this can be obtained by performing a measurement of the Hall effect.

The Hall effect

The Hall effect is essentially due to the Lorentz force \vec{F} acting on each electric charge q moving with velocity \vec{v} in a magnetic field \vec{B} .

$$\vec{F} = q\vec{v} \wedge \vec{B} \quad (11)$$

Let us consider a conducting bar (figure 1) immersed into a uniform magnetic field \vec{B} directed along the z axis, with an electric current I_x flowing along the x axis. The Lorentz force F_L on moving charges, both positive and negative, acts in the direction shown by the arrow (figure 1) (independently from the charge sign).

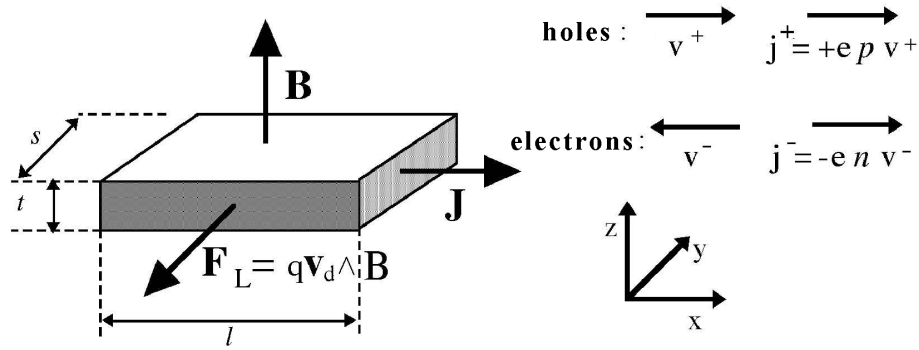


Figure 1: Hall effect geometry

In metals the electric current is only due to electrons. In semiconductors the charge carriers may be either electrons or holes.

In a pure semiconductor the electron density n and the hole density p is identical, in doped semiconductor we have $n \gg p$ (in N-doped material) or $p \gg n$ (in P-doped material). In doped semiconductors only one type of charge carriers is therefore important.

Let us consider first a metal or a N-doped semiconductor sample, where the relevant charge carriers are electrons.

In the electric field E_x the electrons gain a drift velocity $v_d = \mu E_x$ and they are subject to the Lorentz force $F_L = qv_d B$, pointing towards the negative y . While drifting in the x direction they tend to crowd at the sample surface orthogonal to the y axis and placed towards the reader in figure 1.

This charge density increase at the sample lateral surface produces a difference of potential along the y axis and therefore an electric field E_H . The value of the *Hall field* E_H at equilibrium will correspond to an electric force qE_H equal and opposite to the Lorentz force, i.e. $E_H = v_d B$. This relation tells us that the Hall field is proportional both to the current density (through v_d) and to the magnetic field. It is therefore convenient to define the Hall coefficient as:

$$R_H = \frac{E_H}{J_x B_z} \quad (12)$$

Recalling the relations $J_x = -en v_d$ (or $J_x = +ep v_d$) we get :

$$R_H = V_d \frac{B}{J_x B} = \frac{-1}{en} \quad (13)$$

or otherwise, for P-doped conductors:

$$R_H = \frac{+1}{ep} \quad (14)$$

Depending on the type of conductor, either metal (13) , N-doped (13) or P-doped (14).

Measuring R_H we can determine the concentration n of majority carriers and their sign (if we know the direction of the vectors $\vec{B}, \vec{J}, \vec{E}_h$).

We can obtain relation (13) by assuming identical drift velocity for all charge carriers. This is an approximate relation, found in the literature:

$$R_H = \frac{r}{nq} \quad (15)$$

where r is a parameter that accounts for the statistical velocity distribution of the charge carriers, as well as the different scattering mechanisms: $r \approx 1.2$ for mainly phonon scattering (lattice vibrations) and $r \approx 1.9$ for mainly impurity scattering.

The Hall coefficient in semiconductors is many order of magnitude larger than the one in metals, due to the smaller charge density. This makes easier to measure Hall voltages in semiconductors, where a bias current I_x of a few mA may conveniently generate a Hall voltage V_H of in the order of a few mV .

To measure R_H we must know V_H , I_x , B and the sample thickness t :

$$R_H = \frac{E_h}{B J_x} = \frac{V_H}{s} = \frac{B I_x}{ts} = \frac{V_h t}{B I_x} \quad (16)$$

It is worth noting that the the Lorentz force direction does not depend on the charge sign.

The general expression for R_H , valid (see Appendix 1) when *both electrons and holes* are present with densities n and p and mobility μ_e and μ_h is:

$$R_H = r \frac{p\mu_h^2 - n\mu_e^2}{e(p\mu_h - n\mu_e)^2} \quad (17)$$

Which corresponds to the relations and (13) and (14) for $p \gg n$ or $n \gg p$

When two types of charge carriers are present the electrical conductivity becomes:

$$\sigma = e(p\mu_h + n\mu_e) \quad (18)$$

The product $R_H\sigma$, is named Hall mobility μ_H (note the capital index “ H ” that distinguish it from hole mobility μ_h).

For a doped semiconductor the Hall mobility μ_H approximates the *majority carriers* drift mobility $\mu_{h,e}$:

$$\mu_H = R_H\sigma = r \frac{p\mu_h^2 - n\mu_e^2}{p\mu_h + n\mu_e} \approx r\mu_{h,e} \quad (19)$$

From relation (17) we see that by increasing the temperature in a *P-doped sample*, generating many intrinsic⁴ carriers (i.e. electron-hole pairs), the Hall coefficient R_H (which is positive at room temperature in the extrinsic region) tends to decrease, and it may even change sign. This is explained by the mobility ratio $b = \mu_e/\mu_h > 1$. *Note that this does not happen with a N-doped sample.*

From relation (17) at the temperature where $R_H = 0$ (“*inversion point*”) we get $nb^2 = p$, with $p = N_a + N$ and $n = N$ (where N_a is the dopant density and N is the thermally-generated charge density in the intrinsic zone). Therefore $Nb^2 = N_a + N$, or $N_a/N = b^2 - 1$.

The intrinsic conductivity *measured* at the inversion point is:

$$\sigma_{oi} = e(n\mu_e + p\mu_h) = e[N(\mu_e + \mu_h) + N_a\mu_h] = e\mu_h[N(b+1) + N_a] \quad (20)$$

In the extrinsic region of a P-doped sample, where the charge carrier density is constant $n = N_a$, the conductivity is proportional to the carrier mobility μ_h : i.e. $\sigma_e(T) = eN_a\mu_h(T)$

The experimentally measured temperature dependence of the mobility is a power-law $\mu(T) = \text{const}(T^\alpha)$, where the exponent α (in the range $1.5 < \alpha < 3.0$)

⁴*Intrinsic* term labels properties related to pure semiconductors or to doped semiconductors at high temperature, where the thermally generated carriers density is much larger than the (*extrinsic*) carrier density due to the dopant.

depends on the type of prevailing interaction of the charge carriers with phonons, lattice defects or impurities).

Therefore we may *extrapolate the extrinsic conductivity at the inversion point* σ_{ei} , and from the ratio σ_{oi}/σ_{ei} we get the b value:

$$\frac{\sigma_{oi}}{\sigma_{ei}} = e\mu_h \frac{N(b+1) + N_a}{eN_a\mu_h} = \frac{b}{b-1} \quad (21)$$

Which can as well be written as:

$$b = \frac{R_e}{R_e - R_o} \quad (22)$$

where R_o is the measured sample resistance at the inversion point and R_e is the resistance extrapolated from the extrinsic region (low temperature) to the value it would have at the inversion temperature.

The dopant concentration is related to the value of the *Hall constant at the inversion point* R_{Ho} (in the extrinsic region only the hole concentration is significant) by the equations (13) and (14), i.e. :

$$N_a \approx p \approx \frac{1}{eR_{Ho}} \quad (23)$$

The experimental setup

The apparatus uses a Ge sample, cut from a standard P-doped wafer, placed inside a isothermal aluminum case. It is placed in the gap between two poles of a permanent magnet, realized from two neodimium magnets and a U shaped soft-steel core, acting like a torus.

The sample has 7 wires tin soldered in the positions shown in figure [FIX] as follows:

- Contacts 1 and 4 are used to feed the bias current produced by a constant current generator [fix, see figure x]
- Contacts 7 and 5 are used to measured the voltage across the sample, to obtain a 4-wire (often called kelvin) resistance measure. The input is fed to a differential instrumentation amplifier (DA for short).
- Contacts 2-3 and 6 are the output of the Hall voltage and fed to the a second DA.

The potentiometer P [fix] in figure [fix] is used to adjust the balance of the Hall voltage, since the contacts 2 and 3 cannot be precisely positioned. It must be adjusted to obtain $V_H = 0$ when there is no applied magnetic field. Of course the presumed $V_H \neq 0$ we obtain if we do not adjust correctly P is not due to the magnetic field, but to the resistance of the sample itself.

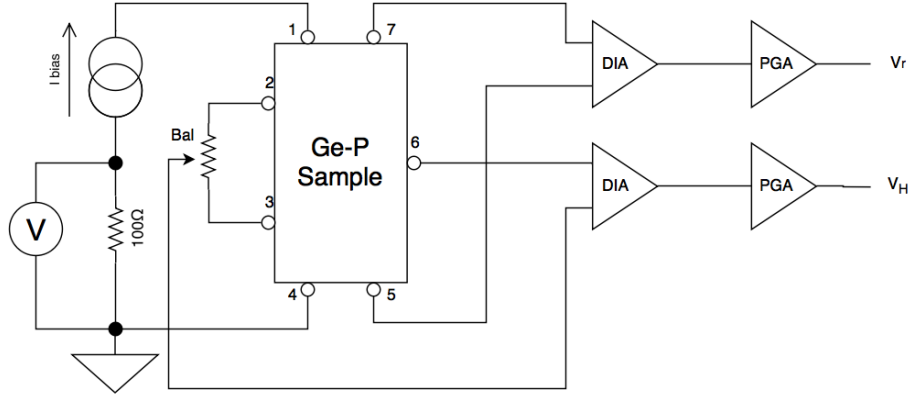


Figure 2: simplified schematic of the sample circuitry

The two DAs have a gain G , generally set to 0.5 for V_r and to 100 for V_H , but it can vary according to instrument specifications, and they're powered from a $\pm 15V$ power supply.

A PGA (Programmable Gain Amplifier) is chained to each of the two DAs, its gain selectable from the following values $G_{PGA} = \{1, 2, 5, 10, 20, 50, 100, 200\}$ using the front panel.

The output voltages on the front panel are restrained by a number of cases:

- If the input voltage is $V_r > \frac{30}{G}$ the DA saturates.
- If the output of the DA is not $0 < V_{out} < 5.1$ it is clamped down by a Schottky diode to prevent damage to the circuitry.
- If the output voltage of a PGA is not $0 < V_{out} < 5$ the PGA saturates

The bias current I_b is measured from the voltage drop across a 100Ω resistor R_i , giving thus an output of $10 \frac{mA}{V}$.

A digital-to-analog (DAC) converter acquires the analog values, sampling them from a $0 < V_{in} < 5$ to a integer value from 0 to 2^{12}

The best value for the bias current is a compromise between the need to obtain a large V_H to make measurements precise reducing the SNR (Signal to Noise Ratio) and a low self-heating of the element due to the Joule effect: V_R and V_H signal are proportional to I while the Joule self-heating is $P = RI^2$

Hall voltage and resistance measurements at room temperature

With a finite value of magnetic field B orthogonal to the large face of the sample, we must measure identical values for V_H (but with opposite sign) when rotating of 180° the sample. This behavior must be tested before proceeding to further measurements: if reversing the B direction (i.e. rotating the sample of 180°

degrees) different values are measured, the offsets and balancing should be better adjusted.

The absolute value of B may be varied by changing the width of the gap between the magnetic poles (see figure [fix]). One of the two permanent-magnet mounted on the soft-steel structure may be moved horizontally by turning the brass-screw: increasing the gap, the value of B decreases.

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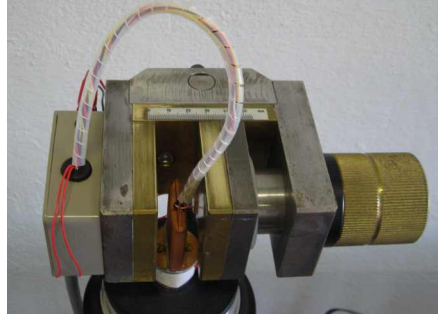


Figure 3: The screw device for changing the effective magnetic field

A calibration of the magnetic field B as a function of the gap may be made using a gauss-meter probe placed between the poles (see figure [fix]).

The magnetic field B may be calibrated using a gauss-meter probe placed at the center between the poles.

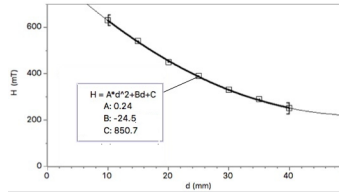


Figure 4: Measured B values vs gap length d

Figure [fix] shows the linear dependence of V_H on I and B . Deviations from linearity at high values of the magnetic field may be explained by calculating a second order approximation of R_H (Appendix 1)

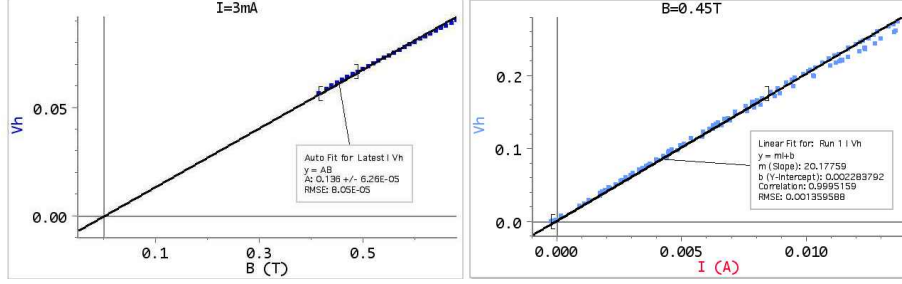


Figure 5: Hall voltage versus bias current I ($B = 4.5kGauss$), and versus B ($I = 3mA$).

Measurements at constant I and B while varying the temperature

The stainless-steel dewar can be filled of liquid nitrogen or a mixture of acetone and dry-ice (solid carbon dioxide). The cold finger (the aluminium bar screwed into the base of the sample) is surrounded by the liquid nitrogen, allowing the sample to be brought to low temperatures.

The temperature is measured by a type K (Chromel-Alumel) thermocouple thermally coupled to the sample. The small voltage generated by the thermocouple is amplified by the AD8495⁵ integrated circuit. The output is vaguely proportional to the temperature, with a sensitivity of $\approx 10 \frac{mV}{K}$. While the K type thermocouple is fairly linear at room temperature, it is not in the wide temperature range covered by the apparatus.

In order to get a correct measurement it is necessary to compensate for the non-linearity (see figure [fix]) of the thermocouple linearly extrapolating the following polynomial:

$$t = d_0 + d_1 E + d_2 E^2 + \dots + d_n E^n \quad (24)$$

where E is the output voltage of the thermocouple.

In the following table⁶ two different groups of coefficients are given, depending on the temperature range:

t range	-200°C to 0°C	0°C to 500°C
d_0	0.000000E+00	0.000000E+00
d_2	2.5173462E+01	2.508355E+01
d_3	-1.1662878E+00	7.860106E-02
d_4	-1.0833638E+00	-2.503131E-01
d_5	-8.9773540E-01	8.315270E-02

⁵AD8495 datasheet, Analog Semiconductors

⁶NIST t-90 tables for K type thermocouples, http://srdata.nist.gov/its90/download/type_k.tab

t range	-200°C to 0°C	0°C to 500°C
V range	-5.891mV to 0mV	0mV to 20.644mV

Linearly extrapolating a polynomial (24) of the fifth order is more than sufficient given the precision of our equipment.

The voltage E at the thermocouple junction can be obtained from the following equation:

$$E = \frac{\frac{1}{2}V_{out} - V_{Ref} - V_{Offset}}{Gain} \quad (25)$$

where V_{out} is the output of the instrument (on the front panel), $V_{Ref} = 2.5V$ the voltage that indicates a temperature $T = 0^\circ C$, V_{offset} is the error voltage at $0^\circ C$ to achieve 125 mV at $25^\circ C$ and $Gain$ is the internal gain of the AD8495 amplifier.

Consequently, linearly extrapolating with the compensation polynomial allows us to finally obtain the correct temperature⁷:

$$t = f_{comp}(E) \quad (26)$$

$$t = f_{comp}\left(\frac{\frac{1}{2}V_{out} - 2.5 - 1.25 \cdot 10^{-3}}{122.4}\right) \quad (27)$$

Cooling-Heating procedure

To obtain accurate measurement it's suggested to first cool off the sample by placing liquid nitrogen in the dewar until a stable temperature is reached, then manually empty the dewar letting it slowly drift up to room temperature (due to the unavoidable thermal coupling sample-to-ambient).

During the cooling process measurements may be taken, but the rapid cooling generates a large thermal gradient across the apparatus that makes such measurements less reliable.

A resistive element is wound around the base of the sample, allowing to heat it up after reaching room temperature. The resistive element is controlled in PWM: it's rapidly powered-on and powered-off with a duty cycle that can be selected (in percentage) on the front panel of the instrument.

[fix, image pwn]

⁷AN-1087, Analog Semiconductors

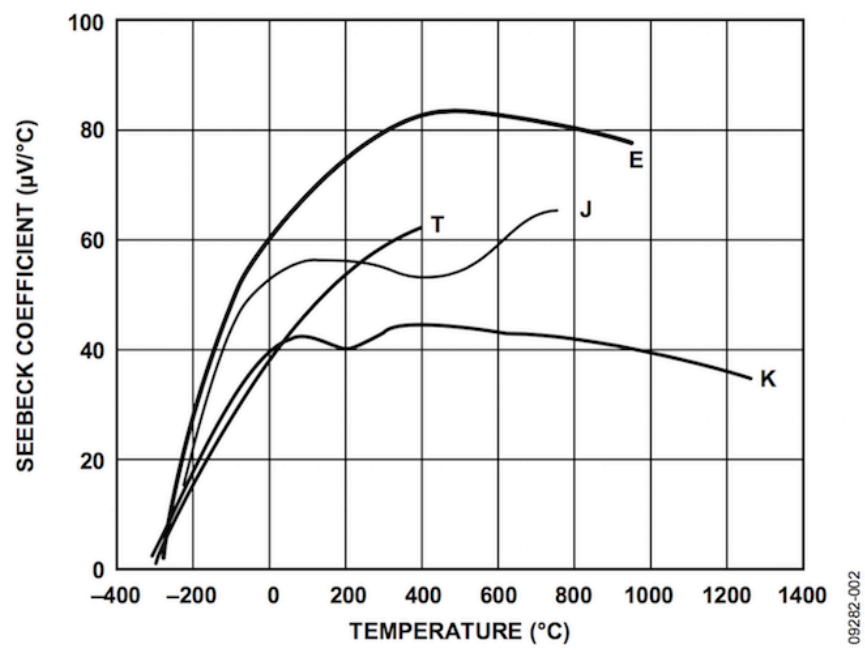


Figure 6: In every type of thermocouple, the Seebeck coefficiently $\frac{\mu V}{^\circ C}$ is heavily non-linear in relation to the temperature.

This technique allows for a linear temperature sweep. Starting with a low power allows to better approximate an equilibrium situation, considering it can subsequently be increased if necessary to reach higher temperatures. The instruments automatically shuts down if $t \geq 150^\circ\text{C}$.

Measurements can be obtained by feeding the analog outputs [fix, quali?] to a data-logger and setting a suitable acquisition rate (e.g. 1 sample per minute)

To obtain precise measurements, at least one complete hour is required for the whole temperature sweep.

Typical results

The sample shown in this example has thickness $t = 0.5\text{mm}$, width $w = 10\text{mm}$ and lenght $l = 15\text{mm}$. The measured Hall voltage and resistance vs temperature (with a constant bias current of $I_B = 30\text{mA}$ and in a 0.5T magnetic field) is shown in figure [fix].

In figure [fix] the resistance is calculated from data of figure [fix].

The logarithmic plot of the resistance versus $\frac{1}{2}kT$ (where $k = 8.617 \cdot 10^{-5} \frac{\text{eV}}{\text{K}}$ is the Boltzmann constant) is shown in figure [fix].

From the slope in the intrinsic region we get the value of the energy gap E_g , extrapolating linearly from $T = 0\text{K}$, that can be compared to the known value for germanium ($E_g^o = 0.78$, cfr. Appendix 2)

[fix, insert image]

Appendix 1: calculation of R_H for small and high magnetic field

The motion equation ($F = ma$) for charge carriers can as well be written as:

$$m\left(\frac{dv}{dt} + \frac{v}{\tau}\right) = qE + q\vec{v} \wedge \vec{B} \quad (28)$$

where the charge q is the $\pm e$ for holes and electrons and we account for the mean time τ between collisions and for the Lorentz force. In stationary conditions the acceleration is zero. Therefore the velocities along x (B is directed along z) for electrons and holes are respectively:

$$V_{ex} = -\frac{e\tau}{m}E_x + \frac{e\tau}{m}\vec{v} \wedge \vec{B} = -\mu_e v_{ey}B \quad (29)$$

$$V_{hx} = \mu_h E_x + \mu_h v_{ex}B \quad (30)$$

And, for velocities along y:

$$V_{ey} = -\mu_e E_y - \mu_e V_{ex} B \quad (31)$$

$$V_{hy} = \mu_h E_y + \mu_h v_{hx} B \quad (32)$$

The current density along the x axis ($J = eV_{hx}P - eV_{ey}n$) can as well be written as:

$$J_x \approx e(p\mu_h + n\mu_e)E_x + e(p\mu_h v_{hy} - n\mu_e v_{ey})B \approx e(p\mu_h + n\mu_e)E_x + e(p\mu_h^2 - n\mu_e^2)BE_y \quad (33)$$

where we made the approximation $v_y \approx \mu_y E_y$, neglecting here the Lorentz force. Recalling that $E_y \ll E_x$, for small magnetic fields B (33) may be approximated by:

$$J_x \approx e(p\mu_h + n\mu_e)E_x \quad (34)$$

For negligible current density along y we have:

$$J_y = epv_{hy} - env_{ey} = 0 \quad (35)$$

or using v_{hx} and V_{ex} definitions:

$$J_y = ep(\mu_h E_y + \mu_h v_{hx} B) - en(-\mu_e E_y - \mu_e v_{ex} B) = 0$$

$$e(p\mu_h + n\mu_e)E_y + e(p\mu_h v_{hx} + n\mu_e v_{ex})B = 0$$

$$E_y = B \frac{p\mu_h v_{hx} + n\mu_e v_{ex}}{p\mu_h + n\mu_e}$$

If again we assume $v_x \approx \mu_x E_x$ (neglecting, for small B, the correction for the Lorentz force we can write:

$$E_y \approx B \frac{p\mu_h^2 - n\mu_e^2}{p\mu_h + n\mu_e} E_x$$

In this way the Hall coefficient becomes:

$$R_H = -\frac{E_y}{J_x B_z} \approx -\frac{p\mu_h^2 - n\mu_e^2}{e(p\mu_h + n\mu_e)^2} \quad (36)$$

The formula (36) holds true only for *small values* of B . For large B values we must use (36) for J_x the definition (33) instead of (34), obtaining for the Hall coefficient R_H :

$$\begin{aligned} R_H(B) &= \frac{E_y}{BJ_x} \approx \frac{\left[B \frac{(p\mu_h^2 - n\mu_e^2)}{(p\mu_h + n\mu_e)} E_x \right]}{Be \left[(p\mu_h + n\mu_e) + B^2 \frac{(p\mu_h^2 - n\mu_e^2)^2}{(p\mu_h + n\mu_e)} \right] E_x} = \\ &= \frac{(p\mu_h^2 - n\mu_e^2)}{e(p\mu_h + n\mu_e)^2 \left[1 + B^2 \frac{(p\mu_h^2 - n\mu_e^2)^2}{(p\mu_h + n\mu_e)^2} \right]} = \frac{R_{H(B=0)}}{1 + KB^2} \end{aligned} \quad (37)$$

which tends to saturate at high B values.

Appendix 2: Temperature dependence of E_g

Experimental results consistently shows that the energy gap depends on temperature and for Germanium we can find in the literature the following empirical law:

$$E_g(T) = 0.742 - \frac{4.8 \cdot 10^{-4} T^2}{T + 235} \quad [eV] \quad (38)$$

This may be approximated, in the high temperature region, by a linear law as follows:

$$E_g(T) = A * BT$$

where the constants A is the value of E_g *linearly extrapolated* to $T = 0$:

$$E_g^0 = A = 0.78 eV$$

Since in the intrinsic region (high temperature) the resistance depends on the absolute temperature T as $\exp(\frac{E_g}{2kT})$, a plot of $\ln(R)$ vs $\frac{1}{2}KT$ using a linear approximation for $E_g(T)$ results in a straight line with slope E_g^0

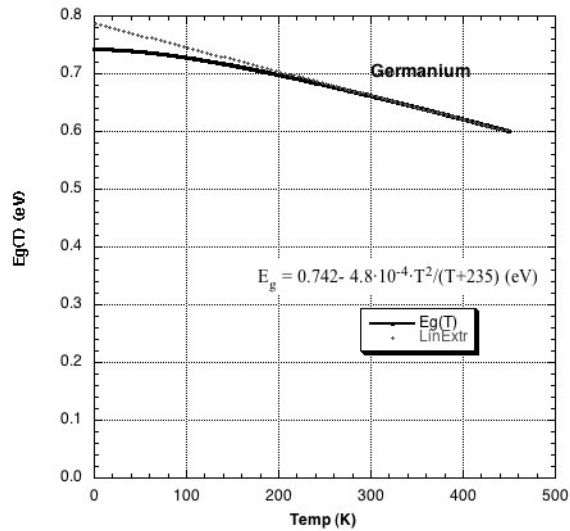


Figure 7: Temperature dependance of the energy gap

Warnings

Using high magnetic field require some caution:

- You must avoid approaching any magnetizable object (clocks, electronic devices, screwdrivers...), which when brought too close may be permanently magnetized.
- A pinch hazard subsists if steel or other ferromagnetic material is placed near the magnets.
- Do not attempt to unscrew the magnets.
- The Magnets are brittle. A rapid shock with another magnet or ferromagnetic material may release shards dangerous for the eye.
- The apparatus **MUST NOT** be used by people with pacemakers.

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